

Docket No.: 4590-500 PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Elias BITAR et al.

Confirmation No. n/a

U.S. Patent Application No. not yet assigned

Filed: herewith

For: METHOD FOR DETERMINING OPTIMAL CHAMFER MASK COEFFICIENTS FOR

DISTANCE TRANSFORM

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449. It is respectfully requested that the documents be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed with the application and no certification or fee is required.

Please note this is a PCT application in the entry of the National Phase in the U.S. and copies of the references cited were transmitted by WIPO and are believed to be in the file of the above-identified application and readily available to the Examiner. Therefore it is believed that Applicants have met all requirements regarding duty of disclosure under 37 CFR 1.56. A copy of the foreign search report is attached for the Examiner's information. Acknowledgement and consideration of these documents are respectfully requested.

Respectfully submitted,

LOWE HAUPTMAN & BERNER, LLP

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INFORMATION DISCLOSURE CITATION IN AN APPLICATION

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